

| | Application No. | Applicant(s) |
|---|---|---|
| | 10/086,155 | KATOH, MASAAKI |
| Notice of Allowability | Examiner | Art Unit |
| | Shouxiang Hu | 2811 |
| The MAILING DATE of this communication appear All claims being allowable, PROSECUTION ON THE MERITS IS (herewith (or previously mailed), a Notice of Allowance (PTOL-85) of NOTICE OF ALLOWABILITY IS NOT A GRANT OF PATENT RIGOT Of the Office or upon petition by the applicant. See 37 CFR 1.313 | OR REMAINS) CLOSED in other appropriate commes in the same of the | in this application. If not included nunication will be mailed in due course. THIS |
| 1. \boxtimes This communication is responsive to $4/20/2006$. | | |
| 2. A The allowed claim(s) is/are 1,8,10 and 26. | | |
| 3. Acknowledgment is made of a claim for foreign priority under a) All b) Some* c) None of the: 1. Certified copies of the priority documents have a copies of the cop | been received. been received in Applicati | on No |
| International Bureau (PCT Rule 17.2(a)). | uments have been receive | ed in this national stage application from the |
| * Certified copies not received: | | |
| Applicant has THREE MONTHS FROM THE "MAILING DATE" o noted below. Failure to timely comply will result in ABANDONME THIS THREE-MONTH PERIOD IS NOT EXTENDABLE. | | e a reply complying with the requirements |
| 4. A SUBSTITUTE OATH OR DECLARATION must be submit INFORMAL PATENT APPLICATION (PTO-152) which gives | | |
| 5. CORRECTED DRAWINGS (as "replacement sheets") must | be submitted. | |
| (a) including changes required by the Notice of Draftsperso | on's Patent Drawing Revie | w (PTO-948) attached |
| 1) hereto or 2) to Paper No./Mail Date | | |
| (b) ☐ including changes required by the attached Examiner's Paper No./Mail Date | | |
| Identifying indicia such as the application number (see 37 CFR 1.8 each sheet. Replacement sheet(s) should be labeled as such in th | 34(c)) should be written on t e header according to 37 C | the drawings in the front (not the back) of FR 1.121(d). |
| 6. DEPOSIT OF and/or INFORMATION about the depos attached Examiner's comment regarding REQUIREMENT F | | |
| Attachment(s) 1. Notice of References Cited (PTO-892) 2. Notice of Draftperson's Patent Drawing Review (PTO-948) | 6. 🛛 Interview S | nformal Patent Application (PTO-152) Summary (PTO-413), ./Mail Date <u>6/1/2006</u> . |
| 3. Information Disclosure Statements (PTO-1449 or PTO/SB/08 | B), 7. ⊠ Examiner's | s Amendment/Comment |
| Paper No./Mail Date 4. Examiner's Comment Regarding Requirement for Deposit of Biological Material | 8. ☐ Examiner's 9. ☐ Other | s Statement of Reasons for Allowance |
| | | 3 Ila |
| | | SHOUXIANG HU PRIMARY EXAMINED |

EXAMINER'S AMENDMENT

An examiner's amendment to the record appears below. Should the changes and/or additions be unacceptable to applicant, an amendment may be filed as provided by 37 CFR 1.312. To ensure consideration of such an amendment, it MUST be submitted no later than the payment of the issue fee.

Authorization for this examiner's amendment was given in a telephone interview with Ilya Chorny (RN: 56,519) on June 1, 2006.

The application has been amended as follows:

IN THE CLAIMS

Claim 1: (currently amended) A light-emitting diode comprising a light-emitting diode chip mounted on a surface of a printed substrate, the light-emitting diode chip including:

a transparent substrate;

a semiconductor layer laminated on the transparent substrate and formed of an N-type semiconductor layer and a P-type semiconductor layer, wherein a PN junction interface between the N-type and P-type semiconductor layers is perpendicular to the surface of the printed substrate, the semiconductor layer including:

a light-emitting portion in the vicinity of the PN junction interface; and

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a first face and a second face, both the first face and the second face parallel to

the transparent substrate wherein the first face is in contact with the transparent

substrate:

a first corner and a second corner adjacent to the surface of the printed

substrate;

a pair of electrodes for applying voltage to the semiconductor layer;

a light reflecting layer formed of a metal thin film formed on the second face of

the semiconductor layer substantially parallel to the PN junction interface and for

reflecting light emitted from the light-emitting portion; and

a recessed section formed only at a- the first corner of the semiconductor layer

adjacent to the printed substrate, the recessed section formed through by removing a

portion of the light reflecting layer and a portion of the semiconductor layer to form an

exposed surface of one of the N-type semiconductor layer and the P-type

semiconductor layer;

wherein a first electrode of the pair of electrodes is formed only at the second

corner on the light reflecting layer and a second electrode of the pair of electrodes is

formed on the exposed surface adjacent to the printed substrate.

Claim 2-7 (cancelled)

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Claim 8 (previously presented): A light-emitting diode claimed in Claim 1, wherein the metal thin film has a thickness of 100 nm or more.

Claim 9 (cancelled)

Claim 10 (previously presented): A light-emitting diode claimed in Claim 1, wherein the transparent substrate is transparent to color emitted by the light-emitting diode chip.

Claim 11 -25 (cancelled)

Claim 26 (previously presented): A light-emitting diode claimed in Claim 8, wherein the transparent substrate is transparent to color emitted by the light-emitting diode chip.

Claim 27 (cancelled)

Allowable Subject Matter

Claims 1, 8, 10 and 26 are allowed.

Conclusion

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Shouxiang Hu whose telephone number is 571-272-1654. The examiner can normally be reached on Monday through Thursday, 7:30 AM to 6:00 PM.

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If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Eddie C. Lee can be reached on 571-272-1732. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free). If you would like assistance from a USPTO Customer Service Representative or access to the automated information system, call 800-786-9199 (IN USA OR CANADA) or 571-272-1000.

SH June 5, 2006

> SHOUXIANG HU PRIMARY EXAMINER

> > EDDIE LEE

SUPERVISORY PATENT EXAMINER TECHNOLOGY CENTER 2800